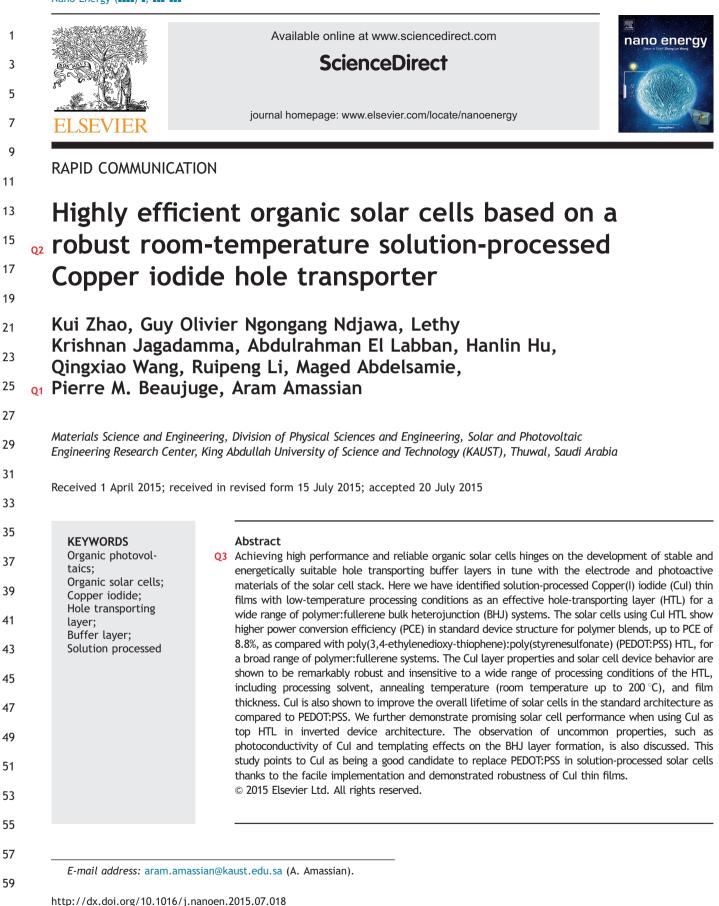
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Introduction

3 Organic photovoltaics (OPV) have attracted tremendous attention in recent years because of the potential for manufacturing solution-processable, large area devices using potentially low cost, non-toxic materials and manufacturing methods which have a reduced carbon footprint [1]. Efficient OPV devices require hole and electron transporting and buffer layers which prevent recombination of charges at the anode and cathode [2,3]. In the standard OPV device architecture, a transparent anode is traditionally coated with poly(3,4-ethylene dioxythiophene):(polystyr-13 ene sulfonic acid) (PEDOT:PSS), so far the most widely used hole-transporting layer (HTL) in OPVs [4]. However, the 15 acidic and hygroscopic characteristics of PEDOT:PSS can cause indium loss from the indium tin oxide (ITO) transpar-17 ent anode, adversely affecting the device stability [5,6]. Recently a few transition metal oxides (TMOs) have been 19 reported as candidate replacements to PEDOT:PSS owing to the energy level compatibility with ITO and to the semi-21 conducting nature of the oxides. This includes materials such as Nickel oxide (NiO_x), [7] Molybdenum oxide (MoO₃), 23 [8] tungsten oxide (WO₃), [9] and Vanadium oxide (V_2O_5) [10]. 25

An important requirement for such TMO materials is their compatibility with solution-processing to enable large-area and high-throughput production of OPV devices. While most hole transporting oxides are typically vacuum deposited, some of them have been successfully shown to be solution processable, including NiO_x, [11] MoO₃ [12] and V_2O_5 [13]. However, research is still directed toward identifying low temperature means of producing such oxides, as many of them require process temperatures incompatible with rollto-roll fabrication of OPV devices on plastic substrates. The oxide thin film synthesis methods can also be complex when compared with PEDOT:PSS thin film deposition and can yield highly variable properties depending upon the processing conditions and environments [14-17].

In this manuscript, we report a room-temperature solution-processed inorganic pseudohalide HTL that is simpleto-process and produces high performance OPV devices over a broad range of preparation conditions. Copper(I) iodide (Cul) is inexpensive, abundant, and non-toxic. It is stable enough to be successfully vacuum-deposited as HTL, [18,19] yet can be easily solution-processed at room temperature [20,21]. Cul was successfully introduced in the past into dye-sensitzed solar cells (DSSCs) by Tennakone and coworkers, [22] in which p-type CuI was used as hole conducting layer [21-27]. Vacuum-deposited Cul has also been used to template the stacking orientation of vacuum-deposited small-molecule thin films such as Zinc phthalocyanine (ZnPc) [28,29] and Copper phthalocyanine (CuPc), [30] as well as polymers such as poly(3-hexylthiophene) (P3HT) [31,32] and poly(4-(2-thiophenaniline)) (P42TA) in OPV applications [33]. Here, we characterize in detail solutionprocessed Cul thin films in terms of their microstructure, optical and electronic properties. We then successfully apply Cul as HTL to get power conversion efficiency (PCE) of up to 4.0% with P3HT:PC₆₀BM, 6.8% with PBDTTPD: PC₇₀BM, 8.0% with PTB7:PC₇₀BM, and 8.8% with PTB7-Th: PC₇₀BM in the standard device architecture, exceeding the performance achieved by PEDOT:PSS with the same material

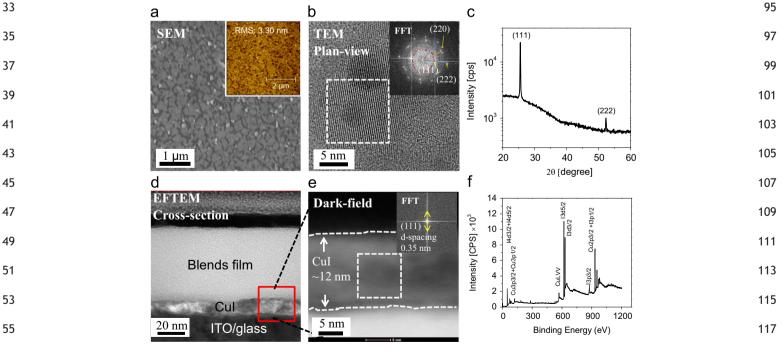


Figure 1 (a) SEM image of a solution-processed Cul film on ITO, inset showing atomic force micrographs of Cul film. (b) Plan-view 57 119 bright-field high resolution TEM (HRTEM) on Cul film deposited on a TEM Copper grid. (c) X-ray diffraction (XRD) spectrum of the 59 solution-processed CuI film (\sim 12 nm) showing (111) and (222) crystalline planes in γ -phase. (d,e) cross-sectional TEM of a CuI film 121 sandwiched between ITO and the organic photoactive layer in an actual device shown on the left. (f) X-ray photoelectron 61 spectroscopy (XPS) of the solution-processed Cul film (\sim 12 nm). The spectrum shows that the film mainly contains Copper and 123 iodine.

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